



Challenges and Advances of Process Control Systems

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Message from the Guest Editors

Dear Colleagues,

The purpose of the Special Issue, titled “Challenges and Advances of Process Control Systems”, is to provide an opportunity for researchers and practitioners to exchange their latest theoretical and technological advances and to identify critical issues and challenges addressing the application and development of various devices of different advanced control algorithms. These algorithms can be based on, but are not limited to, the approaches of robust, optimal, adaptive, predictive control, and intelligent control.

The topics include, but are not limited to, the following control system applications:

- Manufacturing and production processes
- Power generation and distribution
- Robotics
- Hydraulics
- Medicine
- Biotechnology





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Message from the Editor-in-Chief

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